

Analyzing the evidence of a IPR take-off in China and India

8th Ph.D. School on Innovation and Economic Development GLOBELICS ACADEMY 2012

Rio de Janeiro: 20th August – 31st August, 2012

<u>Outline</u>

1. The legal structure of IPRs

- 2. A brief panorama of global IPR demand
- 3. IPR take off in China and India

3 is based on Godinho and Ferreira, Analyzing the evidence of a IPR take-off in China and India, published in Research Policy, Feb. 2012.

4. Further research on Chinese patenting institutions

Intellectual Property Rights (IPR)

		Patents	Technological inventions		
Intellectual Property	Property	Trademarks	Identify supplier, provide differentiation		
. ,		Designs Aesthetic and functional aspects			
	Copyright	Protects inte as films, boo music, painti software + da	llectual creations, such ks, poems, plays, ngs, sculptures or atabases		



Source: http://documents.epo.org/projects/babylon/eponet.nsf/0/BB8A223D7388E491C12572410062FEA0/\$File/patent_granting_procedure_2001onwards_en.gif

Patentability criteria

- **Novelty** An invention is new if it is not part of the "state of the art".
- Utility (or "industrial application") The invention should be useful in order to be patented .
- Non-obviousness (or "inventive step") -The invention shall not be obvious to someone familiar with the patentable subject matter.

The "priority"

- The priority right is triggered by the first filing of an application for a patent.
- The priority period is usually 12 months.
- The priority right allows an applicant to file subsequent applications in other countries for the same invention.

Patent duration: 20 years

Designs

- In different countries: Design Patents, Industrial Designs, Community Designs
- A design is the outward appearance of a product or part of it, resulting from the lines, contours, colours, shape, texture, materials and/or its ornamentation.
- A product can be any item including packaging, graphic symbols and typographic typefaces.

Trademarks

- **Distinctive signs** which identify certain goods or services as those provided by a specific supplier.
- Differentiation and information function: TMs help consumers to identify a product or service and help suppliers to differentiate their products
- **Protection function**: TMs ensure their owners the **exclusive right** to use it or authorize others to use it in return for payment.

What kinds of TMs can be registered?

TMs may be one or a combination of words, letters, and numerals, and they consist of:

- Drawings
- Symbols
- 3-D designs such as the shape and packaging of goods
- Audible signs such as music or vocal sounds
- Fragrances
- Colors used as distinguishing features

TM: Duration

 The period of protection varies, but a trademark can be renewed indefinitely beyond the time limit on payment of additional fees.

Copyright

- Exclusive rights granted to the authors of original works, including the right to copy, distribute and adapt the work.
- Some exceptions under 'fair use'.
- Rights enforceable for a specific period of time (most jurisdictions: life + 70 years), after which the work is said to enter the public domain.
- In many countries: no registration requirement



Each individual country

• National IP laws

Patents

- Paris Convention (1883)
- Patent Convention Treaty (PCT) (1970) (' International Patent')
- European Patent Convention (1973)

Trademarks

- Paris Convention (1883)
- Madrid Agreement(1891) (' International Trademark')
- Community Trademark (1996)

Copyright

• Bern Convention (1886)

Wider legal framework: TRIPS (1994)

- Annex to the 1994 WTO founding treaty
- All WTO members deemed to respect TRIPS
- Harmonization of IP law worldwide
- Integration of the principles of the Paris and Bern conventions on industrial property and copyrights
- Part of the deal to liberalize trade worldwide: access to richer markets by DCs + global enforceability of IPR

What the possibilities are?

- National Patents, TMs, or Industrial Designs (Country X, Country Y etc.)
- International Patent or International TM systems (WIPO) (common application procedure, one examination, granting by national offices)
- Regional systems (Europe; Africa...)
- Which choice??

- **1. The legal structure of IPRs**
- 2. A brief panorama of global IPR demand
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As much as three-quarters of the value of publicly traded companies in America comes from intangible assets, up from around 40% in the early 1980s.

(The Economist, 20 Oct. 2005)

BrandZTM Top 100 Most Valuable Global Brands 2012

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.......

1000

•	Category	Brand	Brand Value 2012 (SM)	Brand Contribution Index	Brand Momentum Index	% Brand Value Change 2012 vs 2011	Rank Change
* * * *	**********	•••••			*********		* * * * * * * *
1	Technology	6	182,951	4	10	19%	0

2	Technology	IBM	115,985	4	5	15%	1
****	* * * * * * * * * * * *	Carla			* * * * * * * * * * * *		* * * * * * * *
3	Technology	Google	107,857	4	5	-3%	-1
****	* * * * * * * * * * * * *		* * * * * * * * * * * *		*********		* * * * * * * *
4	Fast Food		95,188	4	8	17%	0
****	* * * * * * * * * * * * *				* * * * * * * * * * * *		* * * * * * * *
5	Technology	Microsoft	76,651	4	8	-2%	0
* * * *	********				* * * * * * * * * * * *		* * * * * * * *
6	Soft Drinks	(ccaleta.	74,286	5	7	1%	0
* * * *							* * * * * * * *
7	Tobacco	Marihoro	73,612	3	7	9%	1
					* * * * * * * * * * * *		* * * * * * * *
8	Telecoms	😂 atat	68,870	3	5	-1%	-1
* * * *	* * * * * * * * * * * *				* * * * * * * * * * * *		*******
9	Telecoms	1	49,151	3	7	15%	4
		verizyn					
10	Telecoms	○ 中国移动通信 ○ 中国移动通信	47,041	4	9	-18%	-1

- Grandstrand, O., 1999. The Economics and Management of Intellectual Property: Towards Intellectual Capitalism. Edward Elgar Publishing Limited, London.
- Hall, B., 2005. Exploring the Patent Explosion. The Journal of Technology Transfer 302_2, 35-48, 01.

' Patent boom' → USPTO: 1963-2009 (10^3)



' Patent boom'

- New science-intensive sectors
- University patenting
- Strategic use of patents









Source: WIPO Statistics Database, October 2011



Figure A.2.3.1. Patent applications at the top 20 offices, 2010

Note: *2009 data. D.P.R. of Korea = Democratic People's Republic of Korea. The low non-resident shares for France and Italy could partly be explained by that fact the PCT national phase procedure is closed there. A PCT applicant seeking protection in these countries must enter the PCT national phase at the EPO. Source: WIPO Statistics Database, October 2011

Source: WIPO - World Intellectual Property Indicators 2011







Figure B.2.1.2 Trend in applications at selected offices

Source: WIPO Statistics Database, October 2011

Source: WIPO Statistics Database, October 2011

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Questions addressed

- What are the causes behind IPR "takeoff"?
- The same as those behind the "patent explosion" in the US etc. since the 1980s?
- Is there a relationship between such "IPR take-off" and innovation in China and India?
- Questions of sustainability and NIS "fitness"

Observation of the "IPR Take-off"

- Demand on National PTOs
 - National Patents
 - National Trademarks
- Demand on Other Systems





Total trademarks demand (residents and non-residents) in each PTO, 1964-2008



Demand on "other systems"

- International PCT Patents
- National systems: USPTO, JPO, CPO, IPO + EPO
- International trademarks
- National systems + EU CTM system



Total trademarks demand in the EU CTM system, 1996-2007



Technological specialization as given by the chi-squared ratio PCT patent filings, 1989-1998 and 1999-2008



Trademark specialization as given by the chi-squared ratio EU CTM system, 1996-1999 and 2000-2007



4. Further research on Chinese patenting institutions

Top PCT Applicants (applicants with more than 10 PCT applications)

Source: WIPO Statistics Database January 2012

Note: Counts are based on publication date and first-named applicant

	COUNTRY OF	2011 PCT
APPLICANT'S NAME	ORIGIN	APPLICATIONS
ZTE CORPORATION	CN	2,826
PANASONIC CORPORATION	JP	2,463
HUAWEI TECHNOLOGIES CO., LTD.	CN	1,831
SHARP KABUSHIKI KAISHA	JP	1,755
ROBERT BOSCH CORPORATION	DE	1,518
QUALCOMM INCORPORATED	US	1,494
TOYOTA JIDOSHA KABUSHIKI KAISHA	JP	1,417
LG ELECTRONICS INC.	KR	1,336
KONINKLIJKE PHILIPS ELECTRONICS N.V.	NL	1,148
TELEFONAKTIEBOLAGET LM ERICSSON (PUBL)	SE	1,116
NEC CORPORATION	JP	1,056
SIEMENS AKTIENGESELLSCHAFT	DE	1,039
MITSUBISHI ELECTRIC CORPORATION	JP	834
BASFSE	DE	773
SAMSUNG ELECTRONICS CO., LTD.	KR	757
NOKIA CORPORATION	FI	698
INTERNATIONAL BUSINESS MACHINES CORPORATION	US	661
HEWLETT-PACKARD DEVELOPMENT COMPANY, L.P.	US	591
3M INNOVATIVE PROPERTIES COMPANY	US	563
HITACHI, LTD.	JP	547

Top 100 Chinese Patenting Institutions

EPO + USPTO + PCT

2009 + 2010 +2011

(based on published applications)

Top 20 Chinese Patenting Institutions (Score USPTO, EPO, PCT)

		Type of Institution	SCORE
1	HUAWEI TECHNOLOGIES CO. LTD.*	Corporation	100,00%
2	ZTE CORPORATION*	Corporation	66,51%
3	TSINGHUA UNIVERSITY*	University	6,50%
4	BYD COMPANY LIMITED	Corporation	3,88%
5	TENCENT TECHNOLOGY (SHENZHEN) COMPANY LIMITED	Corporation	3,67%
6	LENOVO*	Corporation	3,35%
7	CHINA ACADEMY OF TELECOMMUNICATIONS TECHNOLOGY	R. Institute / Academy	2,74%
8	CHINA IWNCOMM CO. LTD.	Corporation	2,12%
9	TCL CORPORATION*	Corporation	2,10%
10	SEMICONDUCTOR MFG INT SHANGHAI	Corporation	2,06%
11	CHINA MOBILE COMMUNICATIONS CORPORATION	Corporation	1,84%
12	BEIJING BOE OPTOELECTRONICS TECHNOLOGY CO., LTD.	Corporation	1,75%
13	PEKING UNIVERSITY*	University	1,71%
14	NUCTECH COMPANY LIMITED	Corporation	1,61%
15	TSANN KUEN ENTERPRISE CO. LTD.	Corporation	1,34%
16	CHINA PETROLEUM & CHEMICAL CORPORATION (SINOPEC)	Corporation	1,18%
17	XIAMEN SOLEX HIGH-TECH INDUSTRIES CO. LTD	Corporation	1,13%
18	CHERY AUTOMOBILE CO. LTD.	Corporation	1,10%
19	INSTITUTE OF MICROELECTRONICS, CHINESE ACADEMY OF SCIENCES	R. Institute / Academy	1,07%
20	DA TANG MOBILE COMMUNICATIONS EQUIPMENT CO., LTD.	Corporation	1,07%

Score	Business	University	Res.	Total
			Institute	
			/	
			Academy	
			of Sc.	
> 10	2	0	0	2
2-10	6	1	1	8
1-2	8	1	1	10
<1	57	16	7	80
N	73	18	9	100

Top patenting Chinese Universities and Research Institutes / Academies of

3TSINGHUA UNIVERSITY* Science	University	6.5
13PEKING UNIVERSITY*	University	1.71
21NANJING UNIVERSITY	University	0.94
26ZHEJIANG UNIVERSITY	University	0.86
37FUDAN UNIVERSITY	University	0.57
46BEIJING UNIVERSITY OF CHEMICAL TECHNOLOGY	University	0.41
51 EAST CHINA UNIVERSITY OF SCIENCE AND TECHNOLOGY	University	0.36
54SOUTHEAST UNIVERSITY	University	0.32
56SUN YAT-SEN UNIVERSITY	University	0.3
59DALIAN UNIVERSITY OF TECHNOLOGY	University	0.28
60UNIV NORTHEASTERN	University	0.26
73SOUTH CHINA UNIVERSITY OF TECHNOLOGY	University	0.21
75SHENYANG PHARMACEUTICAL UNIVERSITY	University	0.21
78SHANGHAI JIAOTONG UNIVERSITY	University	0.2
81HUAZHONG AGRICULTURAL UNIVERSITY	University	0.2
89XIAMEN UNIVERSITY	University	0.17
90UNIV PLA 2ND MILITARY MEDICAL (Second Military Medical University)	University	0.17
92JIANGSU UNIVERSITY	University	0.17
7CHINA ACADEMY OF TELECOMMUNICATIONS TECHNOLOGY	R. Institute / Academy	2.74
19INSTITUTE OF MICROELECTRONICS. CHINESE ACADEMY OF SCIENCES	R. Institute / Academy	1.07
25SHANGHAI INSTITUTE OF MATERIA MEDICA CHINESE ACADEMY OF SCIENCES	R. Institute / Academy	0.89
32 DALIAN INSTITUTE OF CHEMICAL PHYSICS. CHINESE ACADEMY OF SCIENCES	R. Institute / Academy	0.65
³³ INSTITUTE OF PHARMACOLOGY AND TOXICOLOGY ACADEMY OF MILITARY MEDICAL SCIENCES P.L.A. CHINA	R. Institute / Academy	0.59
45 ⁴⁵ ACADEMY OF SCIENCES	R. Institute / Academy	0.41
49SHANGHAI INSTITUTES FOR BIOLOGICAL SCIENCES. CHINESE ACADEMY OF SCIENCES	R. Institute / Academy	0.37
85CHINA ELECTRIC POWER RESEARCH INSTITUTE	R. Institute / Academy	0.19
87 CHONGQING PHARMACEUTICAL RESEARCH INSTITUTE CO LTD.	R. Institute / Academy	0.18

Grant rate at the EPO, USPTO and SIPO, sample of patents for the TOP 100

		2004	2005	2006	2007	2008
Applications	EPO	44	93	145	51	6
	USPTO	37	78	149	107	70
	SIPO	95	166	99	28	1
Grants	EPO	25	50	51	21	1
	USPTO	27	54	92	70	29
	SIPO	85	132	59	10	0
Grant Rate	EP	56,82%	53,76%	35,17%	41,18%	16,67%
	US	72,97%	69,23%	61,74%	65,42%	41,43%
	SIPO	89,47%	79,52%	59,60%	35,71%	0,00%

Top Chinese Applicants at the USPTO

	2002-2004	2005-2008	2008-2011
Total	244 (30)	2056 (67)	4114 (95)
Huawei ZTE Tsinghua Un.	77 2 30	978 239 144	1527 457 409
Concentration	43%	78%	58%

Huawei Technologies PCT*

2000 —							<u> </u>				
1800 —	G10L - S	peech An	alysis or S	Synthesis							
1600 —	🔳 H04J - N	1ultiplex (Communio	cation							
1400	H04Q - S	Selecting	Arrangen	nents)							
1400	■ G06F - E	letrical Di	gital Data	Processi	ng						
1200 —	H04M -	Telephoni	c Commu	inication							
1000 —	H04N - F	Pictorial C	ommunic	ation							
800 —	Outros										
600 —	H04B - T	ransmissi	on								
400	■ H04W -	Wireless	Communi	cation Ne	tworks						
100	H 04L - T	ransmissi	on of Digi	tal Inform	nation						
200 —											
0											
2000) 2001	2002	2003	2004	2005	2006	2007	2008	2009	2010	2011

ZTE Corporations PCT*



Application to Grant – Huawei (USPTO+EPO+JPO+KIPO)

AP - GR	2006	2007	2008	2009	2010	2011	2012	TOTAL - G	TOTAL - AP	Grant Rate
2004	0	0	4	2	2	1	0	9	12	75%
2005	1	2	4	12	15	10	3	46	67	69%
2006	0	1	2	18	29	14	5	69	141	49%
2007	0	0	3	6	23	23	11	66	161	41%

Application to Grant – ZTE (USPTO+EPO+JPO+KIPO)

										TOTA	TOTAL -	Grant
	2004	2005	2006	2007	2008	2009	2010	2011	2012	L - G	AP	Rate
2004	0	0	0	0	0	1	7	5	1	14	33	42%
2005	0	0	1	1	1	1	6	8	1	19	67	28%
2006	0	0	0	1	0	2	3	10	2	18	54	33%
2007	0	0	0	0	0	0	0	7	4	11	135	8%

Conclusions

IPR take-off in China and India:

- 1. Causes not 100% the same as those behind "patent explosion" in US etc...; related to innovation but also part of a "proprietary rush"
- 2. Innovation becoming central to India and China growth (patents + TMs = innovation) (quality concern)
- 3. This might guarantee continued economic growth
- 4. Catch-up in volume but overall not yet per capita
- Problems of NIS cohesion as certain regions (Shanghai, Pearl River Delta, Bengalore, Mumbai) might catch up with advanced economies over the next 2-3 decades while others left behind

6. Eventually "quality problem"

Thank You !